**DECLARATION** 

I, Atsuko Ikeda, residing at 26-2-906, Ojima 3-chome, Koto-ku, Tokyo,

Japan, do hereby certify that I am conversant with the English and Japanese

languages and am a competent translator thereof. I further certify that to

the best of my knowledge and belief the attached English translation is a

true and correct translation made by me of U.S. Provisional Patent

Application No. 60/496,664 filed on August 21, 2003.

I further declare that all statements made herein of my own

knowledge are true and that all statements made on information and belief

are believed to be true; and further that these statements were made with

the knowledge that willful false statements and the like so made are

punishable by fine or imprisonment, or both, under Section 1001 of Title 18

of the United States Code and that such willful false statements may

jeopardize the validity of the application or any patent issuing thereon.

Signed this 3rd day of June, 2004

Houko Theda

Atsuko Ikeda

[NAME OF DOCUMENT] Specification

[TITLE OF THE INVENTION]

Chip Solid Electrolyte Capacitor
[TECHNICAL FIELD]

[0001]

The present invention relates to a chip solid electrolyte capacitor with low equivalent series resistance (ESR) and good leakage current (LC value).

[BACKGROUND ART]

[0002]

shown in the perspective view of Fig. 3, conventionally known chip solid electrolyte capacitor has a structure that one solid electrolyte capacitor element (2) where an oxide dielectric film layer, a semiconductor layer and an electrically conducting layer are formed in this order on a surface of a sintered body comprising a valveacting metal or an electrically conducting oxide is used, a part of the electrically conducting layer and an anode lead (4a) (anode part) connected to the sintered body are laid on a pair of opposedly disposed end parts (la and lb) which are a part of a plate-like metal-made lead frame (1) and each works out to an external terminal, respective parts are electrically or mechanically connected, the entirety is then molded with a jacketing resin while leaving outside only the external terminal parts of the lead frame to form

a jacket part (5), and the lead frame outside the jacket part is cut and bent at predetermined portions.

[0003]

On the other hand, with recent progress of highfrequency processing of electronic devices, the electrolyte capacitor is also demanded to have good highfrequency performance. The present inventors have already proposed in JP-A-5-234829 (the term "JP-A" as used herein means an "unexamined published Japanese patent application") (Patent Document 1) a chip solid electrolyte capacitor exhibiting good high-frequency performance values, where a plurality of solid electrolyte capacitor elements each obtained by sequentially stacking an oxide dielectric film layer, a semiconductor layer and an electrically conducting layer to form a cathode part on a surface of an anode substrate having an anode part and comprising a valve-acting metal are used and where the cathode parts are partially laid in parallel with no gap on one end part of a lead frame having a pair of opposedly disposed end parts, the anode parts are laid on another end part, respective parts are electrically or mechanically joined, the entirety is molded with a resin while leaving outside a part of end parts of the lead frame, and the lead frame outside the resin mold is cut and bent at predetermined portions.

For maintaining the electric charge supplied to the

inside of capacitor, the chip solid electrolyte capacitor is demanded to have an LC value as low as possible.

[0004]

[Patent Document 1] JP-A-5-234829

[DISCLOSURE OF THE INVENTION]

[Problems to be Solved by the Invention]

[0005]

When a large number of chip solid electrolyte capacitors are produced by laying a plurality of the above-described capacitor elements in a row, the average LC value sometimes increases.

[Means to Solve the Problems]

[0006]

As a result of intensive investigations to solve this problem, the present inventors have found that the increase in the average LC value is highly probably ascribable to a stress acting to separate the resin at the time of molding a plurality of capacitor elements gaplessly laid in parallel on a frame and when on at least a part of the plurality of capacitor elements, a fixing layer which is extending across the capacitor elements and fixing the capacitor elements with each other is stacked and then the capacitor elements are molded, the problem can be solved. The present invention has been accomplished based on this finding.

[0007]

That is, the present invention relates to the following chip solid electrolyte capacitor and electronic devices using the chip solid electrolyte capacitor.

[8000]

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- 1. A resin-molded chip solid electrolyte capacitor comprising a plurality of solid electrolyte capacitor elements horizontally laid in parallel with no gap on a pair of opposedly disposed end parts of a lead frame, and a fixing layer which is extending across the plurality of capacitor elements and fixing the capacitor elements with each other.
- 2. The chip solid electrolyte capacitor described in 1 above, wherein the solid electrolyte capacitor is produced by stacking an oxide dielectric film layer, a semiconductor layer and an electrically conducting layer in this order to form a cathode part on a surface exclusive of the anode part at one end of an anode substrate comprising a sintered body of a valve-acting metal or an electrically conducting oxide or comprising the sintered body connected with a metal wire, and the anode part and the cathode part each is laid to come into contact with the lead frame.
- 3. The chip solid electrolyte capacitor as described in 1 above, wherein the fixing layer is a resin

layer or an electrically conducting layer.

- 4. The chip solid electrolyte capacitor as described in 2 above, wherein the anode part comprises a distal end of the anode substrate.
- 5. The chip solid electrolyte capacitor as described in 2 above, wherein the anode part comprises a metal wire or foil connected to the sintered body.
- 6. The chip solid electrolyte capacitor as described in 5 above, wherein the metal wire is selected from tantalum, niobium, aluminum, titanium, alloys mainly comprising such a metal, and these metals and alloys which are partially oxidized and/or nitrided.
- 7. The chip solid electrolyte capacitor as described in 2 above, wherein the valve-acting metal or electrically conducting oxide is tantalum, aluminum, niobium, titanium, an alloy or niobium oxide mainly comprising such a valve-acting metal, or a mixture of two or more members selected from these valve-acting metals, alloys and electrically conducting oxides.
- 8. The chip solid electrolyte capacitor as described in 7 above, wherein the valve-acting metal, alloy or electrically conducting oxide is subjected to at least one treatment selected from carbidation, phosphation, boronation, nitridation and sulfidation.
  - 9. The chip solid electrolyte capacitor as

described in 2 above, wherein the sintered body has a chemically and/or electrically etched surface.

- 10. The chip solid electrolyte capacitor as described in 2 above, wherein the boundary between the anode part and the part exclusive of the anode part of the anode substrate is insulated by an insulating resin.
- 11. The chip solid electrolyte capacitor as described in 2 above, wherein the oxide dielectric layer mainly comprises at least one member selected from  ${\rm Ta_2O_5}$ ,  ${\rm Al_2O_3}$ ,  ${\rm TiO_2}$  and  ${\rm Nb_2O_5}$ .
- 12. The chip solid electrolyte capacitor as described in 2 above, wherein the semiconductor layer is at least one member selected from an organic semiconductor layer and an inorganic semiconductor layer.
- 13. The chip solid electrolyte capacitor described in 12 above, wherein the organic semiconductor is at least one member selected from an organic semiconductor comprising benzopyrroline tetramer and chloranil, organic semiconductor mainly comprising tetrathiotetracene, organic semiconductor mainly comprising tetracyanoan quinodimethane, and an organic semiconductor mainly comprising an electrically conducting polymer obtained by doping a dopant to a polymer containing a repeating unit represented by the following formula (1) or (2):

[Chem. 1]

$$\begin{bmatrix}
R^1 & R^2 \\
X & X \\
R^5
\end{bmatrix}$$
(1)
$$\begin{bmatrix}
R^1 & R^2 \\
R^3 & R^4
\end{bmatrix}$$
(2)

(wherein R<sup>1</sup> to R<sup>4</sup>, which may be the same or different, each represents a hydrogen atom, an alkyl group having from 1 to 6 carbon atoms or an alkoxy group having from 1 to 6 carbon atoms, X represents an oxygen atom, a sulfur atom or a nitrogen atom, R<sup>5</sup> is present only when X is a nitrogen atom, and represents a hydrogen atom or an alkyl group having from 1 to 6 carbon atoms, and each of the pairs R<sup>1</sup> and R<sup>2</sup>, and R<sup>3</sup> and R<sup>4</sup> may combine with each other to form a cyclic structure).

14. The chip solid electrolyte capacitor as described in 13 above, wherein the electrically conducting polymer containing a repeating unit represented by formula (1) is an electrically conducting polymer containing a structure unit represented by the following formula (3) as a repeating unit:

[Chem. 2]

$$\begin{array}{c|c}
\hline
 R^{6}O & OR^{7} \\
\hline
 S & & \\
\hline
 (3) & & \\
\end{array}$$

(wherein R<sup>6</sup> and R<sup>7</sup> each independently represents a hydrogen atom, a linear or branched, saturated or unsaturated alkyl group having from 1 to 6 carbon atoms, or a substituent for forming at least one 5-, 6- or 7-membered saturated hydrocarbon cyclic structure containing two oxygen elements when the alkyl groups are combined with each other at an arbitrary position, and the cyclic structure includes a structure having a vinylene bond which may be substituted, and a phenylene structure which may be substituted).

- 15. The chip solid electrolyte capacitor as described in 13 above, wherein the electrically conducting polymer is selected from polyaniline, polyoxyphenylene, polyphenylene sulfide, polythiophene, polyfuran, polypyrrole, polymethylpyrrole, and substitution derivatives and copolymers thereof.
- 16. The chip solid electrolyte capacitor as described in 15 above, wherein the electrically conducting polymer is poly(3,4-ethylenedioxythiophene).
  - 17. The chip solid electrolyte capacitor as

described in 12 above, wherein the inorganic semiconductor is at least one compound selected from molybdenum dioxide, tungsten dioxide, lead dioxide and manganese dioxide.

- 18. The chip solid electrolyte capacitor as described in 2 above, wherein the electrical conductivity of the semiconductor is from  $10^{-2}$  to  $10^3$  S/cm.
- 19. A method for producing a chip solid electrolyte capacitor, comprising placing and joining a plurality of solid electrolyte capacitor elements horizontally parallel with no gap on a pair of opposedly disposed end parts of a lead frame, stacking a fixing layer which is extending across the plurality of capacitor elements and fixing the capacitor elements with each other, and molding the capacitor elements with a resin while leaving outside the external terminal parts of the lead frame, the solid electrolyte capacitor being produced by stacking an oxide dielectric film layer, a semiconductor layer electrically conducting layer in this order to form a cathode part on a surface exclusive of the anode part at one end of an anode substrate comprising a sintered body of a valve-acting metal or an electrically conducting oxide or comprising the sintered body connected with a metal wire.
- 20. An electronic circuit using the chip solid electrolyte capacitor described in any one of 1 to 18 above.
  - 21. An electronic device using the chip solid

electrolyte capacitor described in any one of 1 to 18 above. [0009]

One embodiment of the chip solid electrolyte capacitor of the present invention is described by referring to the drawings.

Fig. 1 is a perspective view showing one example of a chip solid electrolyte capacitor using three solid electrolyte capacitor elements. In this example, the chip solid electrolyte capacitor has a structure that the cathode parts of three solid electrolyte capacitor elements (2) each produced by stacking an oxide dielectric film layer, a semiconductor layer and an electrically conducting layer in this order to form a cathode part (3) on a surface of an anode substrate (4) comprising a valve-acting metal or an electrically conducting oxide and being connected with an anode part lead (4a) are partially laid in parallel with no gap on one end part (la) of a lead frame (l) having a pair of opposedly disposed end parts, the anode part leads (4a) are laid on another end part (1b), a fixing layer (6) extending across those three capacitor elements is further stacked before orafter electrically mechanically joining respective parts, the entirety is molded with a resin while leaving outside the external terminal parts of the lead frame (1), and the lead frame is cut and bent at predetermined portions (not shown) outside

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the resin mold.

[0010]

The fixing layer (6) is sufficient if it extends across three capacitor elements, and this layer may extend across almost the entire face of each element as in the embodiment of Fig. 1 or may extend across a part of each element as in Fig. 2 which is a perspective view showing another example of the chip solid electrolyte capacitor of the present invention. The fixing layer preferably extends across almost the entire face.

[0011]

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The chip solid electrolyte capacitor of Fig. 2 has a structure that the cathode parts (3) of three solid electrolyte capacitor elements (2) each produced stacking an oxide dielectric film layer, a semiconductor layer and an electrically conducting layer in this order on a surface of an anode substrate comprising a valve-acting metal or an electrically conducting oxide to form a cathode part (3) while allowing an anode part (4) to remain at an end part of the solid electrolytic capacitor element are gaplessly laid in parallel on one end part (la) of a pair of opposedly disposed end parts of a lead frame (1), the anode part parts (4) are laid on another end part (1b), a fixing layer (6) extending across those three capacitor elements is further stacked before or after electrically or

mechanically joining respective parts, the entirety is molded with a resin while leaving outside the external terminal parts of the lead frame (1), and, similarly to the example of Fig. 1, the lead frame is cut and bent at predetermined portions outside the resin mold.

[0012]

Examples of the valve-acting metal or electrically conducting oxide for use in the present invention include tantalum, aluminum, niobium, titanium, an alloy or niobium oxide mainly comprising such a valve-acting metal, and a mixture of two or more members selected from these valve-acting metals, alloys and electrically conducting oxides. The valve-acting metal, alloy, electrically conducting compound or the like may be partially subjected to at least one treatment selected from carbidation, phosphation, boronation, nitridation and sulfidation before use.

[0013]

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The anode substrate for use in the present invention is a sintered body obtained by shaping the powder of valveacting metal or electrically conducting oxide and then sintering it. The surface area of the sintered body can be varied by appropriately selecting the shaping pressure and sintering conditions (temperature and time). After the sintering, the sintered body surface may be chemically and/or electrically etched to more increase the surface

area of the sintered body.

[0014]

In the present invention, a part of the anode substrate (4) is used as the anode part. As shown in Fig. 2, a distal end of the anode substrate may be assigned to the anode part or as shown in Fig. 1, a metal wire (4a) may be connected to a part of the anode substrate and used as the anode part. Instead of a metal wire, a metal foil may also be used. The metal wire (or metal foil) may be connected after the sintered body is produced, or a part of the metal wire (or metal foil) may be embedded at the shaping before the production of sintered body and then sintered, thereby taking the connection. As for the kind of the metal wire (or metal foil), examples thereof include tantalum, niobium, aluminum, titanium, alloys comprising such a metal, and these metals and alloys which are partially oxidized and/or nitrided. The diameter of the metal wire is usually 1 mm or less and in the case of a metal foil, the thickness is usually 1 mm or less. For the purpose of preventing the semiconductor layer described later from attaching to the portion serving as the anode part to cause short-circuiting of the capacitor, the anode part and the remaining part of the anode substrate may be insulated by attaching an insulating resin like a hair band to the boundary therebetween.

[0015]

Examples of the oxide dielectric film layer which is formed on the anode substrate surface excluding the anode part in the present invention (the oxide dielectric film layer may also be present on the entire or a part of the anode part) include a dielectric layer mainly comprising at least one member selected from metal oxides such as Ta<sub>2</sub>O<sub>5</sub>, Al<sub>2</sub>O<sub>3</sub>, TiO<sub>2</sub> and Nb<sub>2</sub>O<sub>5</sub>. The dielectric layer can be obtained by electrochemically forming the anode substrate in an electrolytic solution. Also, as described in International Publication WOOO/75943, a dielectric layer obtained by mixing a dielectric layer mainly comprising at least one member selected from metal oxides and a dielectric layer for use in ceramic capacitors may be used.

[0016]

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Representative examples of the semiconductor layer which is formed on the dielectric layer in the present invention include at least one compound selected from organic semiconductors and inorganic semiconductors.

Specific examples of the organic semiconductor include an organic semiconductor comprising benzopyrroline tetramer and chloranil, an organic semiconductor mainly comprising tetrathiotetracene, an organic semiconductor mainly comprising tetracyanoquinodimethane, and an organic semiconductor mainly comprising an electrically conducting

polymer obtained by doping a dopant to a polymer containing a repeating unit represented by the following formula (1) or (2):

[0017]

[Chem. 3]

$$\begin{bmatrix}
R^1 & R^2 \\
X & X \\
R^5
\end{bmatrix}$$
(1)
$$\begin{bmatrix}
R^1 & R^2 \\
X & R^5
\end{bmatrix}$$
(2)

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[0018]

wherein R<sup>1</sup> to R<sup>4</sup>, which may be the same or different, each represents a hydrogen atom, an alkyl group having from 1 to 6 carbon atoms or an alkoxy group having from 1 to 6 carbon atoms, X represents an oxygen atom, a sulfur atom or a nitrogen atom, R<sup>5</sup> is present only when X is a nitrogen atom, and represents a hydrogen atom or an alkyl group having from 1 to 6 carbon atoms, and each of the pairs R<sup>1</sup> and R<sup>2</sup>, and R<sup>3</sup> and R<sup>4</sup> may combine with each other to form a cyclic structure.

Preferred examples of the electrically conducting polymer containing a repeating unit represented by formula (1) include an electrically conducting polymer containing a structure unit represented by the following formula (3) as

a repeating unit:

[0019]

[Chem. 4]

$$\begin{array}{c|c}
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[0020]

wherein R<sup>6</sup> and R<sup>7</sup> each independently represents a hydrogen atom, a linear or branched, saturated or unsaturated alkyl group having from 1 to 6 carbon atoms, or a substituent for forming at least one 5-, 6- or 7-membered saturated hydrocarbon cyclic structure containing two oxygen elements when the alkyl groups are combined with each other at an arbitrary position, and the cyclic structure includes a structure having a vinylene bond which may be substituted, and a phenylene structure which may be substituted.

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[0021]

The electrically conducting polymer containing such a chemical structure is being electrically charged and a dopant is doped thereto. For the dopant, known dopants can be used without limitation.

Examples of the polymer containing a repeating unit represented by formula (1), (2) or (3) include polyaniline,

polyoxyphenylene, polyphenylene sulfide, polythiophene, polyfuran, polypyrrole, polymethylpyrrole, and substitution derivatives and copolymers thereof. Among these, preferred are polypyrrole, polythiophene and substitution derivatives thereof (e.g., poly(3,4-ethylenedioxythiophene)).

[0022]

Specific examples of the inorganic semiconductor include at least one compound selected from molybdenum dioxide, tungsten dioxide, lead dioxide and manganese dioxide.

When the organic or inorganic semiconductor used has an electrical conductivity of  $10^{-2}$  to  $10^3$  S/cm, the capacitor produced can have a small ESR value and this is preferred.

[0023]

As for the method of forming the semiconductor layer, conventionally known methods such as method using electrolytic polymerization (see, JP-A-60-37114), method using electrolytic polymerization of an anode substrate treated with an oxidizing agent (see, Japanese Patent No. 2,054,506), and method using chemical deposition (see, Japanese Patent No. 2,044,334) may be employed.

[0024]

In the present invention, an electrically conducting layer is provided on the semiconductor layer formed by the

above-described method or the like. The electrically conducting layer can be formed, for example, by the solidification of electrically conducting paste, plating, vapor deposition of metal, or adhesion of heat-resistant electrically conducting resin film. Preferred examples of the electrically conducting paste include silver paste, copper paste, aluminum paste, carbon paste and nickel paste, and these may be used individually or in combination of two or more thereof. In the case of using two or more pastes, the pastes may be mixed or may be superposed one on another as separate layers. The electrically conducting paste applied is then solidified by allowing it to stand in air or under heating.

[0025]

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The electrically conducting paste mainly comprises a resin and an electrically conducting powder such as metal. Depending on the case, for example, a solvent dissolving the resin or a hardening agent for the resin is added, and the solvent dissipates at the time of solidification. As for the resin, various known resins are used, such as alkyd resin, acrylic resin, epoxy resin, phenol resin, imide resin, fluororesin, ester imidamide resin, amide resin and styrene resin. As for the electrically conducting powder, a powder of silver, copper, aluminum, gold, carbon, nickel or an alloy

comprising such a metal is used. The content of the electrically conducting powder is usually from 40 to 97 mass%. If the content is less than 40%, the electrically conducting paste is small in the electrical conductivity, whereas if it exceeds 97%, the electrically conducting paste disadvantageously causes adhesion failure. The electrically conducting paste may be used after mixing thereto a powder of the above-described electrically conducting polymer or metal oxide for forming the semiconductor layer.

[0026]

Examples of the plating include nickel plating, copper plating, silver plating and aluminum plating. Examples of the metal vapor-deposited include aluminum, nickel, copper and silver.

Specifically, for example, carbon paste and silver paste are stacked in this order on the anode substrate having formed thereon the semiconductor layer.

In this way, a solid electrolyte capacitor element where a cathode part is formed by stacking layers up to the electrically conducting layer on the anode substrate is produced.

[0027]

In the production of the chip solid electrolyte capacitor of the present invention, a plurality of the

thus-produced solid electrolyte capacitor elements prepared, the cathode parts of respective solid electrolyte capacitor elements are partially laid in parallel with no gap on one end part of a separately prepared lead frame having a pair of opposedly disposed end parts, the anode parts of anode substrates are laid on another end part, respective parts are electrically or mechanically joined, for example, by solidification of an electrically conducting paste for the former and by spot-welding for the latter, the entirety is molded with a resin while leaving outside a part of each end part of the lead frame, and the lead frame is cut and bent at predetermined portions outside the resin mold.

[0028]

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In the present invention, it is important that after a plurality of capacitor elements are placed on predetermined portions of a lead frame and electrically or mechanically joined to the lead frame or before joining these elements, a fixing layer extending across capacitor elements is stacked on at least a part of the plurality of capacitor elements. In the scope of the present invention, there is also included an embodiment where the cathode parts of a plurality of capacitor elements are in advance partially connected by using an electrically conducting paste while laying these parts in parallel and aligning the

direction before placing a plurality of capacitor elements on predetermined portions of a lead frame, a fixing layer extending across the elements is further stacked on at least a part of respective faces of the plurality of capacitor elements opposing the faces which are afterward laid on a lead frame, and/or a part of respective faces opposing the anode parts, the elements are then, as described above, placed on predetermined portions of a lead frame, and respective connections of anode and cathode are taken.

[0029]

The fixing layer is preferably provided to cover the boundary portions of a plurality of capacitor elements. By covering the boundary portion between respective capacitor elements, for example, the stress acting to separate the capacitor elements from each other generated due to the resin flowed in at the molding can be decreased. As the fixing layer, a resin layer is used, and an electrically conducting layer is preferably used. As for the resin, various known resins are used, such as alkyd resin, acrylic resin, epoxy resin, phenol resin, imide resin, fluororesin, ester resin, imidamide resin, amide resin and styrene resin. The resin preferably undergoes less shrinkage at the solidification and a resin dissolved in a solvent may be used and solidified by drying. The electrically conducting

layer can be formed, for example, by the solidification of electrically conducting paste, plating, vapor deposition of adhesion or of heat-resistant electrically conducting resin film. As for the electrically conducting paste, the electrically conducting pastes described above can be used. On the resin or electrically conducting paste stacked as the fixing layer, at least one material selected from metal foil, polymer film and ceramic sheet may be placed to reinforce the fixing layer. The thickness of the fixing layer (in the case of using a reinforcing material, the thickness including the reinforcing material) determined by taking account of the standard thickness of the produced chip solid electrolyte capacitor. fixing layer is formed by using an electrically conducting material such as electrically conducting paste, the ESR value of the produced chip solid electrolyte capacitor decreases and thus, a certain improvement can be confirmed.

[0030]

More specifically, as shown in Fig. 1, for example, three solid electrolyte capacitor elements are gaplessly laid in parallel on a pair of opposedly disposed end parts of a lead frame and after providing a fixing layer (6) extending across the elements, molded to produce one chip solid electrolyte capacitor having an angular shape, usually a rectangular parallelopiped shape. At the

production of such a solid electrolyte capacitor, a notched part may be provided on a part of the side face and/or the bottom face to form a site for housing the lead frame after cutting, a notched part may be provided, for example, on the top face so as to distinguish the anode and the cathode, or the top face and/or the bottom face may be tapered at a certain angle to facilitate the release of the produced chip solid electrolyte capacitor from the die at the molding with resin.

[0031]

The lead frame is cut as described above and finally works out to external terminals of the chip solid electrolyte capacitor. The shape thereof is a foil or tabular form and the construction material is iron, copper, aluminum or an alloy mainly comprising such a metal. lead frame may be partially or entirely plated with solder, tin, titanium or the like. Between the lead frame and the plating, a primer plating such as nickel or copper may be provided. The lead frame is disposed such that the frames forming two sides face each other with a gap, and by virtue of the presence of a gap, the anode part and the cathode part of each solid electrolyte capacitor element insulated from each other.

[0032]

As for the kind of the resin used in molding the chip

solid electrolyte capacitor of the present invention, known resins for use in molding a chip solid electrolyte capacitor, such as epoxy resin, phenol resin, alkyd resin and aryl ester resin, can be employed. The production machine for performing the molding with resin is preferably a transfer machine.

[0033]

The thus-produced solid electrolyte capacitor may be subjected to an aging treatment so as to repair the thermal and/or physical deterioration of the dielectric layer, which is caused at the formation of electrically conducting layer or at the jacketing.

[0034]

The aging is performed by applying a predetermined voltage (usually, within 2 times the rated voltage) to the solid electrolyte capacitor. The optimal values of aging time and temperature vary depending on the kind capacitance of capacitor and the rated voltage therefore, are determined by previously performing an experiment, but the aging time is usually from several minutes to several days and the aging temperature is usually 300°C or less by taking account of heat deterioration of the voltage-applying jig. The aging may be performed in an air atmosphere or a gas atmosphere such as Ar, N or He and may be performed under reduced pressure,

atmospheric pressure or applied pressure, but when the aging is performed while supplying water vapor, the stabilization of dielectric layer sometimes proceeds. Examples of the method for supplying the water vapor include a method of supplying water vapor from a water reservoir placed in the aging furnace by using the heat.

[0035]

The chip solid electrolyte capacitor of the present invention can be preferably used for circuits using a high-capacitance capacitor, such as voltage stabilizing circuit and noise removing circuit. These circuits can be used in various digital devices such as personal computer, server, camera, game machine, DVD, AV equipment and cellular phone, and electronic devices such as various power sources. The chip solid electrolyte capacitor produced in the present invention is low in the initial LC and therefore, by using this chip solid electrolyte capacitor, electronic circuits and electronic devices having low energy consumption and in turn, small environmental load can be obtained.

[Effects of the Invention]

[0036]

The present invention provides a chip solid electrolyte capacitor where a fixing layer is formed to extend across capacitor elements placed horizontally in parallel with no gap on a lead frame, and according to the

present invention, a chip solid electrolyte capacitor with low ESR and good LC value can be obtained.

[Examples]

[0037]

The present invention is described in greater detail by referring to Examples, however, the present invention is not limited to these Examples.

[0038]

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Examples 1 and 2 and Comparative Example 1:

By using tantalum powder having CV (product of capacitance and electrochemical voltage) of 150,000/g, sintered bodies in a size of 4.5x0.95x1.5 mm were produced (sintering temperature: 1,300°C, sintering time: 20 minutes, density of sintered body: 6.2 g/cm³, Ta lead wire: 0.24 mm¢; a part of Ta lead wire was embedded in the sintered body to run in parallel to the longitudinal direction of the 4.5 mm dimension and the lead wire part protruded from the sintered body was used as the anode part). The sintered body to serve as the anode excluding a part of the lead wire was dipped in an aqueous 1% phosphoric acid solution and electrochemically formed at 80°C for 8 hours by applying a voltage of 9 V between the anode and a Ta plate electrode as the cathode to form an oxide dielectric film layer composed of  $Ta_2O_5$ . Then, an operation of dipping this sintered body excluding the lead wire in a 1:1 mixed

solution of an aqueous 20% lead acetate solution and an aqueous 35% ammonium persulfate solution, allowing it to stand at 40°C for 1 hour, then pulling out, water-washing and drying the sintered body, and washing it with an aqueous 15% ammonium acetate solution was repeated 39 times to form a semiconductor layer composed of a lead dioxide and lead acetate mixture (lead dioxide: 96%) on the oxide dielectric film layer. On the semiconductor layer, carbon paste and silver paste comprising 10 parts of epoxy resin and 90 parts of silver powder were sequentially stacked to complete the cathode part, thereby a producing solid electrolyte capacitor element.

[0039]

On a pair of end parts of a separately prepared 100 µm-thick copper alloy lead frame having a tin-plated surface (32 paired end parts each in a width of 3.4 mm were present; the end part on which the cathode part was laid had a step of 0.8 mm as shown in Fig. 1 and the portion where the cathode part was laid had a length of 4.6 mm; and when coplanarly projected, a gap of 1 mm was present between both end parts), three solid electrolyte capacitor elements produced above were connected horizontally in parallel with no gap (the cathode side of the solid electrolyte capacitor element, namely, the 4.5×0.95 face of the sintered body was laid on the end part having a step

and the anode side of the solid electrolyte capacitor element was laid on another end part; each was electrically or mechanically connected by solidification of silver paste the former and by spot-welding for the latter). Subsequently, as shown in Fig. 1, a fixing layer was provided by using the above-described silver paste on a part of respective connection faces of three capacitor elements in the cathode side opposing the face placed on the lead frame. The fixing layer was provided to cover about 70% of the face of each capacitor element opposing the face in the lead frame side to a maximum thickness of 0.15 mm (Example 1) or to cover 90% to a thickness of 0.35 mm (Example 2) (the values each is an average value of 10 units by random inspection). Also, a sample where a fixing layer was not provided was produced (Comparative Example 1). In each Example, three solid electrolyte capacitor elements were connected on each pair of end parts and 96 solid electrolyte capacitor elements were connected in total on one lead frame. Thereafter, a part of both end parts of the lead frame and the solid electrolyte capacitor elements were molded with epoxy resin by transfer molding to produce a chip solid electrolyte capacitor in a size of 7.3x4.3x2.8 mm. After molding, both end parts outside the resin mold each was cut at the position of 3.4 mm from the end face of the resin mold, the frame cut out was removed and the end

parts connected to the chip solid electrolyte capacitor and remaining outside each was bent along the outer circumference of the capacitor and used as the external terminal. From one lead frame, 32 chip solid electrolyte capacitors were produced.

[0040]

## Example 3:

Chip solid electrolyte capacitors were produced in the same manner as in Example 1 except that the electrically conducting paste used for the fixing layer in Example 1 was replaced by an acrylic resin alone not containing silver powder. The fixing layer was covering about 70% of the face of each capacitor element opposing the face in the lead frame side to a maximum thickness of 0.17 mm.

[0041]

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## Example 4 and Comparative Example 2:

After the procedure until the formation of dielectric layer was performed in the same manner as in Example 1, an operation of dipping the sintered body alternately in a 3% ethylenedioxythiophene alcohol solution and in an aqueous 13% anthraquinonesulfonic acid solution having dissolved therein 1.5% ammonium persulfate was repeated 7 times to attach multiple fine contacts mainly comprising an ethylenedioxy polymer on the dielectric layer, thereby

producing a plurality of fine electrical defective portions in the dielectric layer. According to the observation by a scanning electron microscope (SEM), dot-like fine contacts covering about 88 of the dielectric layer. Subsequently, the sintered body was dipped in electrolytic solution of water and 20% ethylene glycol, where ethylenedioxythiophene (used in the form of an aqueous solution having a monomer concentration lower than the saturated concentration) and anthraquinonesulfonic acid were dissolved, and for forming a semiconductor layer, a direct current voltage of 12 V was passed between the anode assigned to the lead wire of the sintered body and a tantalum electrode as the negative electrode disposed in the electrolytic solution, at room temperature for 45 minutes. The sintered body was then pulled up, washed, dried and subjected to re-electrochemical formation (80°C, 30 minutes, 7 V) in an aqueous 0.1% acetic acid solution to repair the fine LC defects of the dielectric layer. After repeating 10 times the operation of passing the direct current voltage and performing the re-electrochemical formation, the sintered body was washed with water and dried to form a semiconductor layer working as the cathode. On the semiconductor layer, carbon paste and silver paste (comprising 90 parts of acrylic resin and 10 parts of silver powder; the solvent for dissolving the acrylic resin

was present at the beginning but dissipated at the solidification by drying) were sequentially stacked to complete the cathode layer, thereby producing a solid electrolyte capacitor element.

[0042]

Thereafter, solid electrolytic capacitor elements were placed on a lead frame in the same manner as in Example 1 and a fixing layer extending across the elements was provided by using silver paste comprising 90 parts of acrylic resin and 10 parts of silver paste. From samples where the fixing layer was provided to cover about 70% of the face of each capacitor element opposing the face in the lead frame side to a maximum thickness of 0.25 mm (Example 4) or where the fixing layer was not provided (Comparative Example 2), chip solid electrolyte capacitors were produced in the same manner as in Example 1.

[0043]

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Example 5 and Comparative Example 3:

By using 0.023 g of partially nitrided niobium powder (nitrogen amount: 12,000 ppm, total oxygen amount: 98,000 ppm resulting from natural oxidation of the surface) having CV of 190,000/g, many sintered bodies in a size of 4.5×0.94×1.5 mm were produced (sintering temperature: 1,280°C, sintering time: 30 minutes, density of sintered body: 3.6 g/ml, Nb lead wire: 0.29 mmφ). The sintered body

excluding a part of the lead wire was dipped in an aqueous 0.1% phosphoric acid solution and electrochemically formed at 80°C for 5 hours by applying a voltage of 20 V between the sintered body and a Ta plate electrode as the negative electrode to form a dielectric layer mainly comprising Nb<sub>2</sub>O<sub>5</sub>. Then, an operation of dipping this sintered body alternately in a 3% ethylenedioxythiophene alcohol solution and in an aqueous 13% anthraquinonesulfonic acid solution having dissolved therein 1.5% ammonium persulfate was repeated 7 times to attach multiple fine contacts mainly comprising an ethylenedioxy polymer on the dielectric layer, thereby producing a plurality of fine electrical defective portions in the dielectric layer. According to the observation by a scanning electron microscope (SEM), dotcontacts were covering about 11% dielectric layer. Subsequently, the sintered body was dipped in the same electrolytic solution as in Example 4 and for forming a semiconductor layer, a direct current of 30 µA was passed between the anode assigned to the lead wire of the sintered body and a tantalum electrode as the negative electrode disposed in the electrolytic solution, at room temperature for 45 minutes. The sintered body was then pulled up, washed, dried and subjected to reelectrochemical formation (80°C, 30 minutes, 14 V) in an aqueous 0.1% acetic acid solution to repair the fine LC

defects of the dielectric layer. After repeating 10 times the operation of passing the direct current and performing the re-electrochemical formation, the sintered body was washed with water and dried to form a semiconductor layer working as the cathode. On the semiconductor layer, carbon paste and silver paste comprising 90 parts of acrylic resin and 10 parts of silver powder were sequentially stacked to complete the cathode layer, thereby producing a solid electrolyte capacitor element. Thereafter, from samples where a fixing layer was provided to cover about 70% of the face of each capacitor element opposing the face in the lead frame side to a maximum thickness of 0.28 mm (Example 5) or where a fixing layer was not provided (Comparative Example 3), chip solid electrolyte capacitors were produced in the same manner as in Example 4.

[0044]

By preparing 150 units for each of the chip solid electrolyte capacitors produced in Examples 1 to 5 and Comparative Examples 1 to 3, the capacitor capacitance, ESR value and LC value were measured according to the following methods and the results (average value) obtained are shown in Table 1.

Capacitance of capacitor:

- **3**- 1 - 3- 1 - 3- 1

The capacitance was measured at room temperature and 120 Hz by using an LCR measuring meter manufactured by

Hewlett Packard.

## ESR Value:

The ESR value was measured at 100 kHz, which is an index for impedance showing the resistance against alternating current of the capacitor.

## LC Value:

After continuously applying a predetermined direct current voltage (2.5 V for Examples 1 to 4 and Comparative Examples 1 and 2, and 4 V for Example 5 and Comparative Example 3) between terminals of the produced capacitor for 30 seconds at room temperature, the LC value was measured.

[0045] [Tablé 1]

TABLE 1

TABLE I				
		Capacitance (µF)	ESR (mΩ)	LC (µA)
Example	1	1320	`4	31
	2	1320	4	30
	3	1320	6	28
	4	1340	4	36
	5	480	10	28
Comparative Example	1	1320	4	54
	2	1320	4	60
	3	480	11	47

[0046]

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As seen from comparison of Examples 1 to 4 with

Comparative Examples 1 and 2 and comparison of Example 5 with Comparative Example 3, a good LC value can be obtained by forming a fixing layer extending across capacitor elements.

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[BRIEF DESCRIPTION OF THE DRAWINGS]

[0047]

[Fig. 1]

A perspective view of a chip solid electrolyte capacitor, showing the state where three solid electrolyte capacitor elements each having an anode lead (anode part) are placed horizontally in parallel with no gap on end parts of a lead frame.

[Fig. 2]

A perspective view of a chip solid electrolyte capacitor, showing the state where three solid electrolyte capacitor elements each having an anode part in the sintered body itself are placed horizontally in parallel with no gap on end parts of a lead frame.

[Fig. 3]

A perspective view showing a conventional chip solid electrolyte capacitor, where a solid electrolyte capacitor element is placed on end parts of a lead frame.

[Description of Numerical References]

[0048]

1 lead frame

- la one end part of lead frame
- 1b another end part of lead frame
- 2 solid electrolyte capacitor element

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- 3 cathode part
- 4 anode body
- 4b anode lead
- 5 jacket part (chip-like molded resin)
- 6 fixing layer